	L #	Hits	Search Text	DBs
1	L1	812	(524/261).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
2	L3	880	(524/265).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
3	L4	802	(524/267).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
4	L6	985	(524/379).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
5	L7	445	(524/385).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
6	L2	349	(524/264).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
7	L5	498	(524/269).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
8	L8	7	or condensed or	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
9	L9	2958 6	· ·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
10	L10		hollow near5 (polymer or resin)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
11	L11	1755 6	vinyl\$6oxysilane or vinyl adj3 \$10silane or vinyl\$5oxy adj5 silane or \$4ylvinyl\$7oxysilane or vinyl adj3 \$10silane or vinyl\$5oxy adj5 silane or vinyl\$7oxysilane	EPO; JPO; DERWENT;

	L #	Hits	Search Text	DBs
12	L12	171191	\$4yl\$7oxysilane or alkoxysilane or \$7oxysilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
13	L13	435		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
14	L16	406	(1 2 3 4 5 6 7) and 11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
15	L17	246	(nydrolyzss or nydrolysis or partial\$5 near5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
16	L14	20		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
17	L15	4	13 and 10	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
18	L18	10	17 and (9 1 <sub>.</sub> 0)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
19	L19	1	(1 2 3 4 5 6 7) and void adj forming adj solvent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
20	L20	19	17 and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
21	L21	17	20 and solvent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
22	L22	29	16 and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
23	L23	19	(NVQLOLVZSS Or NVQTOLVSIS	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
1	L1	1	INVARATORS WITH	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
2	L2	2878 4	1 3	USPAT; USOCR;
3	L3	2562 7	hollow near5 (polymer or	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
4	L 4	1152	·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
5	L5	376		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
6	L6	90	1 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
7	L8	0	("2004/0198882").URPN.	USPAT
8	L7	62	4 and (2 3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
9	L9	6		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
10	L10	157	5 and 9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
11	L11	1	\$4ylvinyl\$7oxysilane or vinyl adj3 \$10silane or vinyl\$5oxy adj5 silane or vinyl\$7oxysilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
12	L12	2291 0	\$4yl\$7oxysilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
13	L13	3867 2	\$7oxysilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
14	L14	244	(9 11) same (12 13) same hydrolyzate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
15	L16	0	3 and 14	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
16	L15	5	2 and 14	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
17	L17	4	(9 11) same (12 13) and hydrolyzate and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
18	L18	79	(9 11) same (12 13) and hydrolyzate and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
19	L19	39		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L#	Hits	Search Text	DBs
20	L20	2	("20040198882").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
21	L21	273	(9 11) and (12 13) and hydrolyz\$5 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
22	L22	58	21 and silica near5 film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
23	L25	188	(9 11) and (12 13) and hydrolyz\$5	EPO; JPO; DERWENT
24	L24	8	23 and silica near5 film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
25	L23	61	(9 11) and (12 13) and hydrolyz\$5 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
26	L26	0	hollow adj (polymer or resin) and alkoxysilane and vinylsilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
2,7	L27	27	2 and alkoxysilane and vinylsilane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
28	L28	15	27 and hydrolyz\$5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
29	L29	19	(9 11) same (12 13) same partial\$5 adj condens\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
30	L30	2	("4822828").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
31	L31	0	2 and 30	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
32	L32	0	30 and hollow	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
33	L33	2		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
34	L34	1	(9 11) and 33	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
35	L35	0	(9 11) and (12 13) and partial\$5 adj condens\$3 and hollow adj (polymer or resin)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
36	L36		· ·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
37	L37	19	l .	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
38	L38	271	(9 11) same (12 13) and partial\$5 adj condens\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
39	L39	38	38 and silica near5 film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
40	L40	584	(9 11) same (12 13) same hydrolysis	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
41	L42	2	40 and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
42	L41	16	40 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
43	L43	1	hollow adj (polymer or resin) and silica near5 film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
44	L44	6743	silica near5 film	EPO; JPO; DERWENT
45	L45	11	(9 11) and (12 13) and 44	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
46	L46	23	·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
47	L47	2	void adj forming adj solvent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
48	L48	91	(9 11) and (12 13) and insulat\$5 and semiconductor and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
49	L49	75	48 and (hydrolysis or hydrolyz\$5 or partial\$5 adj condens\$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
50	L50	22	(hydrolyzed or hydrolyzate or condensed or condensate) near10 mixture near10 (9 11) near10 (12 13)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
51	L51	584	insulat\$5 and semiconductor and 3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
52	L52	29	(9 11) and (12 13) and 51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
53	L53	3346	insulat\$5 and semiconductor and silica	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
54	L54	148	•	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
55	L55	48	54 and (2 3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
56	L56	2		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
57	Ĺ57	1		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
58	L58	1305	3 and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
59	L59	6	1 and 58	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
60	L60	162	hollow adj (polymer or resin) and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
61	L61	l	hollow adj (polymer or resin) same coating and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
62	L62	2	("20040034147").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB
63	L63	1	62 and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search Text	DBs
64	L64	1		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB